



PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re A	pplication of:)				
Applica Filed:	ation No.: 10/766,654 January 27, 2004	:) :) :)	Examiner: TBA Group Art Unit: 1771			
P.O. Bo	COMPOSITE MATERIAL Sissioner for Patents ox 1450 dria, VA 22313-1450)	September 16, 2004			

INFORMATION DISCLOSURE STATEMENT

Sir:

In compliance with the duty of disclosure under 37 C.F.R. § 1.56 and in accordance with the practice under 37 C.F.R. §§ 1.97 and 1.98, the Examiner's attention is invited to the documents listed on the enclosed Form PTO-1449. Copies of the listed documents are also enclosed.

I hereby certify that this correspondence is being deposited with the United States Postal Service as first-class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 on

September 16, 2004
(Date of Deposit)

Alicia A. Russo, Reg. No. 46,192
(Name of Attorney for Applicant)

September 16, 2004
Date of Signature

Attorney Docket No. 03137.000005

(provided as U.S. Patent No. 6,586,353).

PATENT APPLICATION

Applicants submit herewith copies of the applications cited in the specification including U.S. Patent Application Serial No. 10/354,220 (provided as U.S. Patent Application Publication No. 2003/0228460); U.S. Patent Application No. 10/354,219 (provided as U.S. Patent Application Publication No. 2003/30176125); U.S. Patent Application No. 10/354,216 (provided as U.S. Patent Application Publication No. 2003/0224679); U.S. Patent Application No. 09/955,395 (provided as U.S. Patent Application Publication No. 2003/0054717); and U.S. Patent Application No. 09/663,255

It is respectfully requested that the information provided herewith be considered by the Examiner and that a copy of the enclosed Form PTO-1449 be returned indicating that such information has been considered.

Applicants' undersigned attorneys may be reached in our New York office by telephone at (212) 218-2100. All correspondence should continue to be directed to our address given below.

Respectfully submitted,

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PATENT APPLICATION

FORM PTO 1449 (modified) U.S. DEPARTMENT OF COMMERCEP 2 0 2004			ATTY DOCKET NO. 03137.000005	APPLICATION NO. 10/766,654						
U.S. DEPARTMENT OF COMMERCEP 2 0 2004 PATENT AND TRADEMARK OFFICE LIST OF REFERENCES CITED BY AFFLICANT(S) (Use several sheets if necessary) APPLICANT Younger Ahluwalia et. al. FILING DATE January 27, 2004 GROUP 1771										
(Use several sneets if necessary			FILING DATE January 27, 2004		GROUP 1771					
U.S. PATENT DOCUMENTS										
*EXAMINER INITIAL	DOCUMENT NUMBER	DATE		NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE			
	6,673,432	01/2004		Kiik et al.	428	301.1				
	6,586,353	07/2003		Kiik et al.	442	320				
	6,228,497	05/2001		Dombeck	428	392				
	5,965,257	10/1999		Ahluwalia	428	357				
	5,540,980	07/1996		Tolbert et al.	428	215				
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	4,994,317	02/1991		Dugan et al.	428	246				
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FOREIGN PATENT DOCUMENTS										
	DOCUMENT NUMBER	DATE		COUNTRY	CLASS	SUBCLASS	TRANSLATION YES/NO/ OR ABSTRACT			
	GB2167060	05/1986		United Kingdom	C04B	14/38				
OTHER DOCUMENT(S) (Including Author, Title, Date, Pertinent Pages, Etc.)										
EXAMINER	EXAMINER DATE CONSIDERED									

^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.